

Sub-diffraction Quantum Dot Waveguides



Jean Wang

Funder NSF Graduate & Intel Ph.D. Fellowships

Affiliation Electrical Engineering

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**Finding a way to guide light within
100's of nm width while reducing loss.**

Motivations:

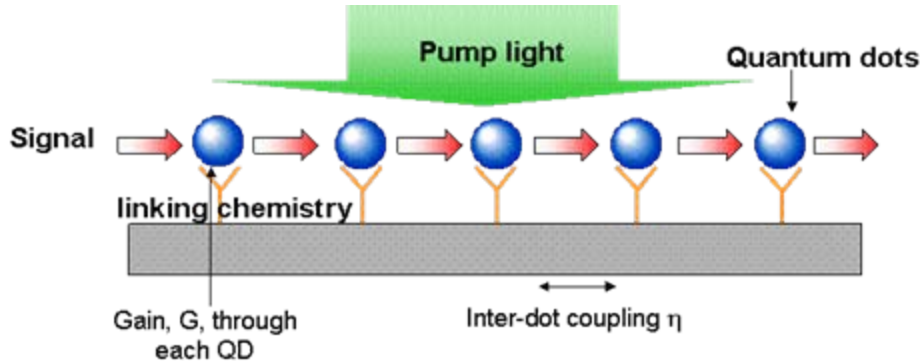
- ** Realizing ultra-high density photonic integrated circuits requires guiding light at sub-diffraction limit dimensions without extensive loss from sharp bends.**
- ** Harness inherent advantages of large bandwidth, capacity and high speed modulation in optical communication at the sub-micrometer scale.**



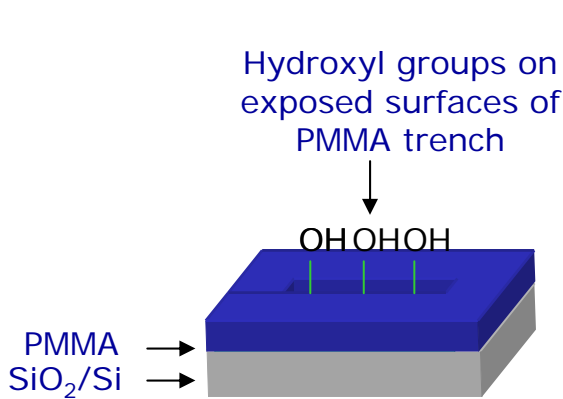
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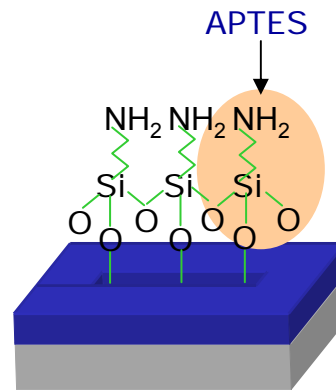
Operation & Fabrication



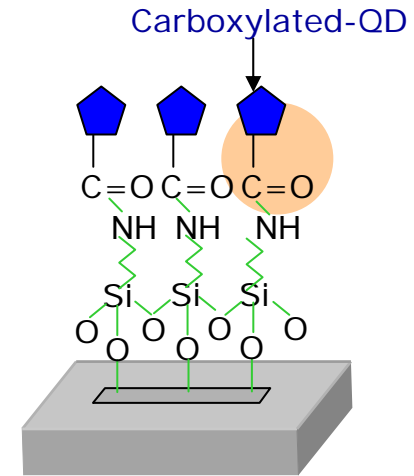
- Gain generated by pump light
- Stimulated emission by signal light
- Optical propagation by energy transfer, characterized by inter-dot coupling efficiency η



- Spin-coat PMMA
- E-beam lithography
- Develop PMMA
- O₂ plasma treatment

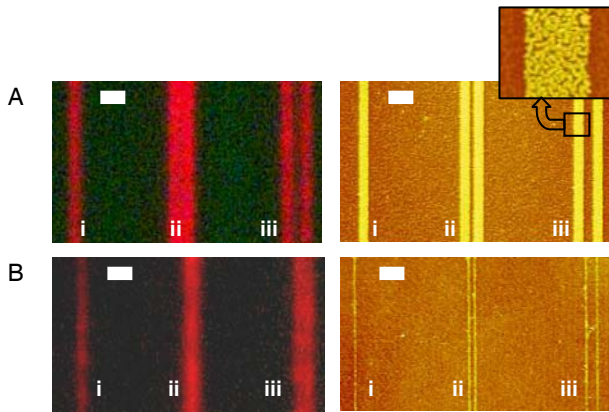


- Form 3'aminopropyltriethoxysilane (APTES) monolayer

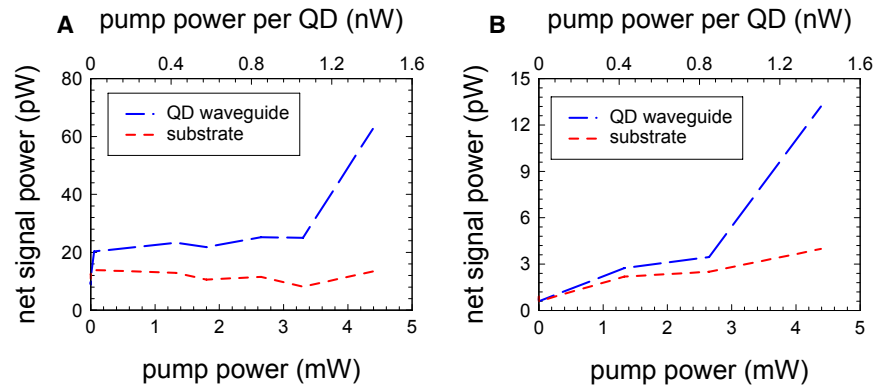


- Covalently bind carboxylated-QDs via EDC, 1-ethyl-3-(3 dimethylaminopropyl)-carbodiimide
- Remove PMMA with dichloromethane

Results & Continuing Work



Fluorescence and corresponding AFM of (A) 500 nm with inset depicting granular QD shape and (B) 100 nm wide waveguides in (i) single and pair formations spaced (ii) 200 nm and (iii) 500 nm apart. Scale bar is 1 μm in length.



Measured transmission results from 500 nm width waveguides demonstrating higher signal on the waveguide than on substrate. (A) 10 μm straight waveguide net signal power and (B) 10 μm x 10 μm corner net signal power.

- Gain mechanism in QD combined with high inter-dot coupling coefficient enable efficient energy transfer
- Demonstrated fabrication via two-layer self assembly with sub-diffraction limit dimensions
- Preliminary test results of sub-diffraction limit devices
- Testing permutations: distance, crosstalk, cornering
- Test multi-QD type devices for crosstalk

